

Notice of References Cited

Application/Control No.

10/622,607

Applicant(s)/Patent Under
Reexamination
CHEN ET AL.

Examiner

Matthew W. Such

Art Unit

2891

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*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
*	A	US-6,417,076	07-2002	Holscher et al.	438/462
*	B	US-6,291,315	09-2001	Nakayama et al.	438/459
	C	US-			
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	M	US-			

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NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.